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Fabrication and Characterization of PLD-Grown Bismuth Telluride (Bi₂Te₃) and Antimony Telluride (Sb₂Te₃) Thermoelectric Devices

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Abstract

We report on the fabrication and characterization of multi-leg bismuth telluride (Bi₂Te₃) and antimony telluride (Sb₂Te₃) thermoelectric devices. The two materials were deposited, on top of SiO₂/Si substrates, using Pulsed Laser Deposition (PLD). The SiO₂ layer was used to provide insulation between the devices and the Si wafer. Copper was used as an electrical connector and a contact for the junctions. Four devices were built, where the Bi₂Te₃ and Sb₂Te₃ were deposited at substrate temperatures of 100°C, 200°C, 300°C and 400°C. The results show that the device has a voltage sensitivity of up to 146 μ V/K and temperature sensitivity of 6.8 K/mV.

Keywords

Thermoelectric Devices, Bismuth Telluride, Bi₂Te₃, Antimony Telluride, Sb₂Te₃, Pulsed Laser Deposition, PLD, Seebeck Effect

1. Introduction

Thermoelectric devices can convert heat to electrical power and vice versa. These devices can be used for many applications, such as micro-cooling and micro-heating. The devices can also be used for converting wasted heat energy from factories, plants, and automobiles to electrical power. Micro-heating and cooling and electrical current generation can be attractive for applications such as powering biomedical sensors, cooling integrated circuits, or operating micro-electromechanical systems (MEMS) devices and sensors.

Thermoelectric devices can be characterized by measuring several parameters that correlate the electrical signals (current and voltage) to the temperature difference. The first parameter used to characterize materials and devices is Seebeck

coefficient. This coefficient relates the difference in voltage, ΔV , to the difference in temperatures, ΔT , between two points [1] [2]. In this case, Seebeck coefficient is a characteristic of the materials. Seebeck coefficient, S, can be expressed as:

$$S = -\Delta V / \Delta T \tag{1}$$

For a device composed of two dissimilar materials (A and B) forming two junctions at their ends, Seebeck coefficient relates ΔV and ΔT of the junctions. Hence,

$$V = (S_A - S_B) \Delta T, \tag{2}$$

where S_A and S_B are Seebeck coefficients for materials A and B, respectively. In this case, the effective Seebeck coefficient for the device is

$$S = S_A - S_B \tag{3}$$

To characterize the thermoelectric performance, Altenkirch found that a dimensionless figure of merit can provide a better indication of the thermoelectric quality of a material than Seebeck or Peltier effects [1] [2] [3]. This figure of merit, ZT, can be expressed as

$$ZT = \frac{\sigma S^2 T}{k} \,, \tag{4}$$

where σ , S, and k are the electrical conductivity, Seebeck coefficient, and thermal conductivity of the material, respectively. From Equation (3), it can be observed that a material with good thermoelectric properties should have high σ , high S, and low k.

For a device built using n-type and p-type materials, the figure of merit, ZT, can be obtained from the following Equation [1]:

$$ZT = \frac{\left(S_p - S_n\right)^2 T}{\left[\left(\rho_n k_n\right)^{0.5} + \left(\rho_p k_p\right)^{0.5}\right]^2},$$
 (5)

where S_n , ρ_n , and k_n are the Seebeck coefficient, the resistivity, and the thermal conductivity of the n-type material, respectively. Similarly, S_p , ρ_p , and k_p are the Seebeck coefficient, the resistivity, and the thermal conductivity for the p-type material, respectively. As indicated by Equation (3), for thermoelectric devices, the Seebeck coefficient of the device is $S = S_p - S_n$.

There are many different materials that can be used to build thermoelectric devices. Chalcogenides group is one type of these thermoelectric materials. They are materials that contain one or more elements such as S, Se or Te as a substantial constituent, such as $CsBi_4Te_6$, Tl_2SnTe_5 and Tl_2GeTe_5 , PbTe, and $ZfTe_5$ [4] [5] [6] [7]. Skutterudites, such as $(Ce_yFe_{1-y})_xCo_{4-x}$, form another set of materials. It was reported that this material has a figure of merit of 1.4 at 1000 K [1]. Half Heusler alloys, such as $Zr_{0.5}Hf_{0.5}NiSb_xSn_{1-x}$, were investigated and found to have $S=10~\mu/K$, at 50 K [8]. Clathrates materials, such as $Eu_8Ga_{16}Ge_{30}$ and $Sr_8Ga_{16}Ge_{30}$, were found to have low thermal conductivity, which results in high figure of merit [9] [10]. Alloys of Te-Ag-Ge-Sb, which is referred to as TAGS,

can provide ZT > 1 [11] [12]. $Ca_3Co_4O_9$ and single-crystal $NaCo_2O_4$ achieved Seebeck coefficient value of 130 and 100 μ V/K, respectively [13] [14].

One of the most promising materials for thermoelectric application is Bismuth telluride (Bi₂Te₃) and Antimony telluride (Sb₂Te₃) [15]. Bi₂Te₃ is a natural *n*-type material while Sb₂Te₃ is a natural *p*-type material [16]. These materials can be grown using many growth techniques such as Chemical Vapor Epitaxy (CVD), sputtering, Molecular Beam Epitaxy (MBE), among other techniques. Shaik and Abdel-Motaleb have grown Bi₂Te₃ and Sb₂Te₃ using Pulsed Laser Deposition (PLD) technique [17]. They have also investigated their electrical and optical characteristics [18] [19]. They have shown that good quality of polycrystalline materials of Bi₂Te₃ and Sb₂Te₃ can be grown using PLD.

In this paper, we designed and fabricated thermoelectric devices using PLD-grown 4-pair legs of n-Bi₂Te₃ and p-Sb₂Te₃. The thermoelectric properties of the materials and the devices are investigated. To the best of our knowledge, there is very few published report about the fabrication of a multi-leg, PLD-grown Bi₂Te₃ and Sb₂Te₃ thermoelectric devices. In fact, we could not identify one credible report. Therefore, we believe that this study will advance the state of the art of this area.

2. Device Design

The thermoelectric device consists of an n-type and a p-type material connected electrically in series and thermally in parallel. The materials used in this device are n-type Bi_2Te_3 and p-type Sb_2Te_3 , with copper acting as the metal contact between the two materials. The devices were built on a 3-inch p-Si wafer, with $3000^{\circ}A$ of thermally grown SiO_2 on top [20]. The SiO_2 is used just for isolating the devices from the p-Si wafer. The dimensions of each area of the Bi_2Te_3 and Sb_2Te_3 are 0.4 inch \times 0.12 inch. Both materials have 8 regions connected with copper contacts as shown in **Figure 1(a)**. In this figure, the red is Bi_2Te_3 , the blue

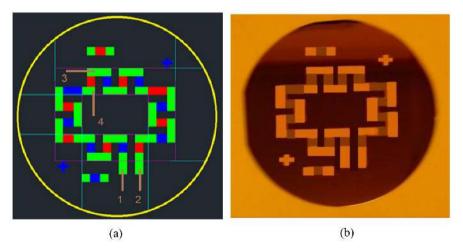


Figure 1. The thermoelectric device. (a) The masks for the tree layers: the red is for the Bi_2Te_3 , the blue is for Sb_2Te_3 , and the green is for the copper metal. (b) A photograph of the device after fabrication.

is for Sb_2Te_3 and the green color depicts and copper metal. The dimensions for the copper are roughly 0.34 inches \times 0.12 inches.

Bi₂Te₃ and Sb₂Te₃ were grown using the PLD technique. The copper connections were deposited using the electron beam evaporation technique. Three different shadow masks for Bi₂Te₃, Sb₂Te₃ and the copper were designed and manufactured for the use in building the devices; see **Figure 1(a)**. The finished thermoelectric device is shown in **Figure 1(b)**.

3. Material Deposition

Bi₂Te₃ and Sb₂Te₃ were deposited using Neocera-PLD system [21]. After loading the substrate and mounting the targets for the two materials, the turbo pump was turned on to reduce the pressure to the level of 10⁻⁶ Torr. The substrate temperature was maintained to the set value using a 3-inch heater. The heater is capable of reaching a maximum temperature of 850°C. The deposition of Bi₂Te₃ and Sb₂Te₃ was carried out in Argon atmosphere. In this study, four devices were fabricated by depositing these materials at substrate temperatures of 100°C, 200°C, 300°C, and 400°C. The deposition targets used in the PLD system are 99.999% pure hot pressed Bi₂Te₃ and Sb₂Te₃ with a diameter of 1-inch and a thickness of 0.125-inch each.

After the chamber was pumped down to about 5×10^{-6} Torr, Ar gas was admitted to increase the chamber pressure to the desired deposition pressure of 7.5 mTorr. The substrate temperature increased from room temperature to the required temperature by ramping the heater at 10° C/minute. KrF laser was applied to the target for 2 hours for a total of 72,000 pulses. The laser beam parameters were set to the following values: incident angle equal 45° , frequency equal 10 Hz, and energy equal 250 mJ. The targets were set to rotate during the deposition in order to reduce exfoliation.

For each device, both Bi₂Te₃ and Sb₂Te₃ were deposited at the same substrate temperature. During the deposition, the substrate was covered with its respective shadow mask to form the desired device geometry. Copper metal contacts were deposited using the electron beam evaporation technique and patterned using the shadow mask designed for this purpose.

4. Material Characterization

Dektak profilometer was used to measure the thickness of the deposited films. With a vertical resolution of \sim 5 A. The average thickness was found to be 400 μ m for all films, as intended.

The surface morphology of Bi₂Te₃ and Sb₂Te₃ films were characterized using HITACHI S-4500 Scanning Electron Microscope (SEM). The SEM images of the device were obtained by firing the electron beam at 3 kV. Images with magnification of 2.5 K were taken for Bi₂Te₃ and Sb₂Te₃ films deposited at the different deposition temperature, as shown in **Figure 2** and **Figure 3**.

Bi₂Te₃ deposited at 100°C was found to be rough with irregular formation of

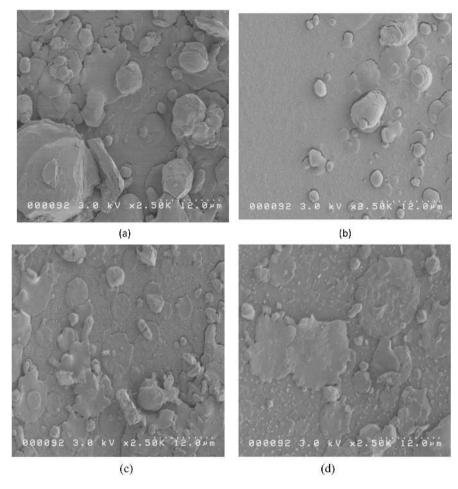


Figure 2. SEM images of Bi_2Te_3 films with magnification of 2.5 K for films deposited at substrate temperature of (a) 100° C (b) 200° C (c) 300° C (d) 400° C.

grains. The films deposited at 200°C were found to have smoother surfaces compared to other films. For the higher temperature substrates, Bi₂Te₃ surfaces became rough again with large sizes of island structures. The roughness can be attributed to the high substrate temperatures that caused the grains to over grow and induce roughness [2]. Over growth could be due to the combination of small grains to from lager grains, by a process called secondary recrystallization [16]. However, for Sb₂Te₃ films, we found that there was not much difference seen between films deposited at 200°C and 300°C.

5. Measurement of Effective Seebeck Coefficient or Voltage Sensitivity

To obtain the effective Seebeck coefficient for a device, Seebeck coefficients for the constituent materials (Bi₂Te₃ and Sb₂Te₃) should be known first. The effective Seebeck coefficient for the device can then be calculated from Equation (3). Another way to obtain the effective Seebeck coefficient for the entire device is to measure it experimentally. This requires that both voltage and temperature differences be measured across the device junction. In our case, we do not have a

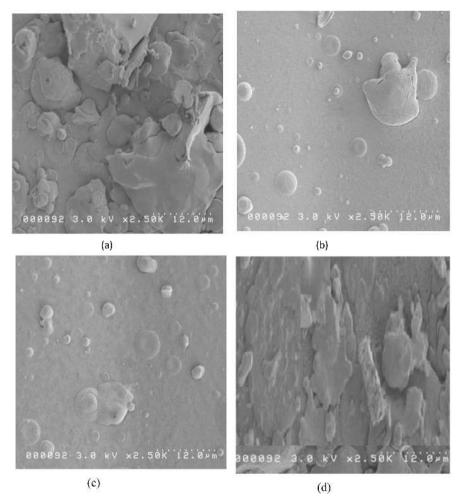


Figure 3. SEM images of Sb_2Te_3 films with magnification of 2.5 K for films deposited at substrate temperature of (a) $100^{\circ}C$ (b) $200^{\circ}C$ (c) $300^{\circ}C$ (d) $400^{\circ}C$.

simple one junction device, but rather a more complicated multi-leg device, which requires a more elaborate technique.

In our case, the effective Seebeck coefficient was measured by applying a voltage across points 1 and 2 and measuring the temperature difference between points 3 and 4. Points 1, 2, 3, and 4 are indicated in Figure 1(a). It should be noted that points 1 and 2 are chosen for voltage application because they are the input ports of the device, where the legs are electrically connected in series. On the other hand the temperature difference was measured across junctions 3 and 4. It should be noted that the temperature difference can be measured across any two junctions, and this would still represent the temperature difference across the entire device. This is true because the device legs are thermally connected in parallel, and the temperature difference across any junctions is the same.

In our case, the voltage was supplied using a high precision voltage supply and measured using high resolution voltmeter. The temperature difference, ΔT , was measured using SA1-K (Chromega-Alomega) type thermocouple. This thermocouple can measure temperatures from -60°C to 175°C continuously with a

time response of 0.3 seconds. This thermocouple has a silicon based cement adhesive attached to a polyimide adhesive pad. Two thermocouples were used for measuring the temperature across the junctions. One lead of the thermocouple was attached to junction 3 using the adhesive pad, while the other lead was connected to the thermal read out using a connector. After applying the desired voltage across points 1 and 2, the temperature of junction 3 was measured from the reading of the thermal read out. Similarly the temperature of junction 4 was measured using the other thermocouple. The difference between the readings of the two thermal readouts gave the temperature difference across junctions, 3 and 4.

As shown in **Figure 4**, the device with a material deposition temperature of 100° C has temperature difference (ΔT) varied from 0 to 3 K for an applied voltage from 0 to 0.25 mV. The temperature difference remained almost constant when the voltage increased beyond this value. This may be due to the heat loss, resulting from thermal leakage to the substrate and radiation to the surroundings. This may also be due to the fact that none of the junctions were maintained at constant room temperature using a heat sink. As a result, the temperatures at

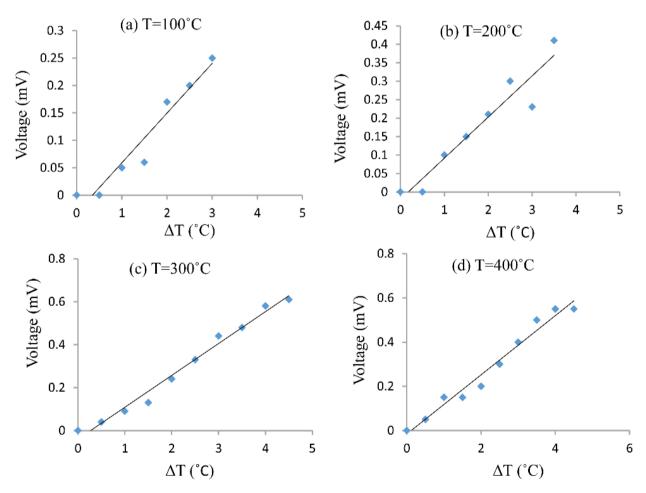


Figure 4. Temperature difference between the junctions when voltage is applied at the terminals of device with substrate temperatures of (a) 100°C (b) 200°C (c) 300°C (d) 400°C.

both the junctions changed simultaneously reducing the temperature difference between the junctions. However, this effect would not be prominent, if the applied voltage is kept low. For this reason, the applied voltage was maintained at low values to ensure accurate results.

For the device built with material deposition temperature of 200°C, ΔT increased to 3.5 K when a voltage of 0.41 mV was applied. For the device built at 300°C, ΔT increased to 4.5 K when a voltage of 0.61 mV was applied. Finally for the device deposited at 400°C, ΔT increased to 4.5 K when 0.55 mV was applied at the terminals 1 and 2. Similar to the first device, no further increase in ΔT was observed when the voltages were increased beyond these values.

The ratio of the voltage applied to the temperature difference gives the effective Seebeck coefficient for the device, or. This ratio is the slope of the graph in Figure 4. From this Figure, it can be shown that the effective Seebeck coefficients are 93 μ V/K, 100 μ V/K, 146 μ V/K and 132 μ V/K for the devices with deposition temperatures of 100°C, 200°C, 300°C and 400°C, respectively. It was observed that the effective Seebeck coefficient increases with the increase of the substrate temperature, reaching a maxima at 300°C, then decreases after that. The increase could be due to the decrease in the thermal conductivity of the materials at high deposition temperatures [22]. The subsequent decrease could be due to the excessive increase in the resistivity of Bi₂Te₃ which leads to the increase of the voltage drop outside the junction, reducing the effective ΔV . Kimi and Oh reported the fabrication of electrodeposited 196 pairs of Bi₂Te₃ and Sb₂Te₃ thin film legs thermopile [23]. They controlled the temperature difference of the thermopile and measured the voltage difference. When the temperature difference was set to 14°C, a maximum sensitivity of 57.5 mV/K was obtained. This high value of the voltage sensitivity is attributed to the large number of pairs of legs and the size of device layers.

6. Thermal Conductivity

There are various methods used for the measurement of thermal conductivity of thin films. Among these methods are the thermal conductance, thermal diffusive, thermos-reflectance, the laser flash, and the 3ω method [24] [25]. In this work, the thermal conductivity values were taken from the literatures [24] [26]. The thermal conductivity for Bi_2Te_3 for different growth temperatures are shown in **Table 1**. For Sb_2Te_3 , thermal conductivity values for PLD-grown films at the

Table 1. Thermal conductivity values of Bi₂Te₃.

Substrate temperature	Thermal conductivity of Bi_2Te_3 (Wm ⁻¹ ·K ⁻¹) [24] [26]	Resistivity of Bi_2Te_3 ($\mu\Omega$ ·m) (This work)	Resistivity of Sb_2Te_3 $(\mu\Omega \cdot m)$ (This work)
100°C	1.75	40	24
200°C	1.5	44	17.68
300°C	0.9	68	16
400°C	0.8	84	15

same growth temperatures are hard to find in the literature. Therefore, an average value of thermal conductivity of 1.63 $Wm^{-1}\cdot K^{-1}$ was used for all films of Sb_2Te_3 [27].

7. Electrical Conductivity

The measured electrical parameters of Bi₂Te₃ and Sb₂Te₃ films, obtained using the four point probe technique, are shown in **Figures 5(a)-(c)**. The Figure shows

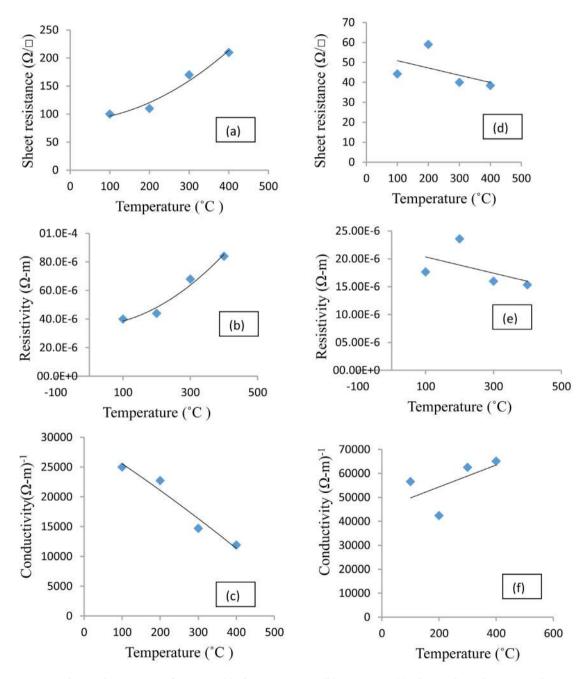


Figure 5. Electrical Parameters for Bi_2Te_3 (a) Sheet Resistance (b) Resistivity (c) Electrical conductivity with temperature. Electrical Parameters for Sb_2Te_3 (d) Sheet Resistance (e) Resistivity (f) Electrical conductivity with temperature.

the effect of substrate temperature on the sheet resistance, resistivity and the electrical conductivity. The value of the sheet resistance for $\mathrm{Bi_2Te_3}$ was found to increase with the substrate temperature, with a maximum value of 210 (Ω/\Box) at 400°C. When the substrate temperature increases, grains over grow resulting in increasing the roughness and irregularities in the film. This results in increasing the sheet resistance of the film. This increase may be due to carrier scattering at the rough boundaries of the grains, which increases with the growth temperature [18]. Consequently, the resistivity increases and the conductivity decreases with increasing the substrate temperature. These findings have also been observed in references [18] [28].

The sheet resistance was measured for Sb_2Te_3 films using the four point probe too. The measured values of the sheet resistance, resistivity and the electrical conductivity, as a function of the substrate growth temperature, are shown in **Figures 5(d)-(f)**. As shown in the Figure, the resistivity of the films, and consequently the sheet resistance, changes only by about $\pm 15\%$ from the average value. Therefore, the sheet resistance and resistivity can be assumed to be almost constant with temperature, even though they have decreasing values. The conductivity will behave accordingly.

The resistivity of Sb₂Te₃ films behaves differently from Bi₂Te₃ films, where the resistivity remains almost constant with growth temperature. This behavior can be attributed to the finding that the grain size of PLD-grown Sb₂Te₃ films does not change with the temperature growth. Hence the level of scattering of the carriers at the grain boundaries is the same for all samples. The same behavior has been observed and reported by in references [18] [29].

8. Figure of Merit and Power Factor

To the best of our knowledge there is no published report on the figure of merit of multi-leg devices built using PLD-grown $\mathrm{Bi_2Te_3}$ and $\mathrm{Sb_2Te_3}$. However, there are reports of calculated figure of merit when the material thin film is used individually to build the device.

The figure of merit of one pair of p-n legs thermoelectric device can be calculated using Equation (5). The values of the device effective Seebeck coefficient (voltage sensitivity) and Bi₂Te₃ and Sb₂Te₃ electrical resistivity and thermal conductivity are obtained from Sections 5, 6, and 7 above. The Seebeck values measured are for the entire 4-pair legs device. Since these devices are electrically connected in series, the Seebeck coefficient of one pair of Bi₂Te₃ and Sb₂Te₃ leg is 25% of the measured value. These values are used in our calculation of the Figure of Merit (ZT) and the Power Factor (PF), shown in **Table 2**. The power factor (PF) measures the performance of the device and can be obtained from the equation $PF = S^2 \sigma$. When calculating the PF, the effective resistivity of the two materials becomes $r = r_n + r_p$ and the effective thermal conductivity becomes $k = k_n + k_p$, since the dimensions of the n region is the same as those of the p-region [30].

Substrate temperature (°C)	Device effective seebeck coefficient (Voltage sensitivity) (µV/K)	Effective electrical resistivity for one pair, $r(\mu\Omega \cdot m)$	Effective thermal con- ductivity for one pair, k (Wm ⁻¹ ·K ⁻¹)	Figure of merit (ZT) measurements at room temperature for one pair	Power factor for one pair $PF = \mathcal{S} \cdot \sigma$ $(\mu W/K^2 \cdot m)$
100	93	84	3.38	7.586×10^{-4}	8.446
200	100	61.68	3.13	0.001	10.133
300	146	84	2.53	0.003	20.816
400	132	101	2.43	0.002	10.96

Table 2 shows the values of ZT and the PF of one pair of legs deposited at different growth temperatures. The two parameters for the device were calculated at room temperature. It can be observed that the figure of merit increases for the substrate temperature until 300°C and then it decreases for the device with a substrate temperature of 400°C. The power factor behaves exactly the same way. For devices with growth temperatures at 100°C, 200°C and 300°C, the thermal conductivity of the device was found to decrease with temperature and this is accompanied by an increase in the effective Seebeck coefficient, which results in the increase in the figure of merit and the power factor of the device. The decrease for device built at 400°C can be attributed to the slight decrease in the electrical conductivity and the effective Seebeck coefficient at that temperature.

The performance of our devices can be enhanced if more pairs of legs are used. Kimi and Oh reported the fabrication of 196 pairs of Bi_2Te_3 and Sb_2Te_3 thin film legs thermopile using electrodeposition [23]. They reported a voltage sensitivity from 57.5 mV/K for the entire device. However by dividing the reported sensitivity value by 196 (the number of pairs of legs), the value is reduced to 293 μ V/K. Our voltage sensitivity values have been affected by the fact that the device was not thermally isolated and without a heat sink. This resulted in the loss of heat due to radiation and thermal conductivity. Our simulation shows that by using a heat sink, the voltage sensitivity will increase by 25% - 200% [31].

Using Seebeck coefficient or voltage sensitivity for all types of thermoelectric devices may not provide an accurate evaluation of the performance of some types of devices. This because a device designed for cooling is different from that built for energy harvesting. The optimum parameters for one type may not be the optimum for another type. Similar to an amplifier, the characteristics for a common base configuration is different from a common emitter configuration. One has high current gain but low voltage gain and the other has higher gain for both.

The devices reported here use politer effect, not Seebeck effect. The input to our device is voltage and the output is temperature difference. Hence the device sensitivity should be temperature sensitivity $\Delta T/\Delta V$, not voltage sensitivity, which is related to Seebeck Coefficient. To differentiate between the two para-

meters, let us call the voltage sensitivity S_V and the temperature sensitivity S_T . Let us now compare the device reported in [23] by Kimi and Oh, with our device. For our device the highest value for S_V is 146 μ V/K for the 4 pairs of legs device fabricated at 300°C. This means for one leg, $S_V = 36.5 \mu$ V/K. For Kimi and Oh device the maximum $S_V = 57.5 \, \text{mV/K}$ for 196 pairs. This means for a pair of legs, $S_V = 293 \, \mu$ V/K, which is higher than our device. However, if we compare the temperature sensitivity for one pair, we will find that our device has $S_T = 27.4 \, \text{K/mV}$ compared with Kimi and Oh device, where $S_T = 3.4 \, \text{K/mV}$. This means our device is geared to obtain higher temperature sensitivity, since it is used for cooling/heating based on politer effect. On the other hand, Kimi and Oh device is geared for energy harvesting, hence it should have higher voltage sensitivity. Temperature sensitivity can be obtained from the voltage sensitivity where $S_T = 1/S_V$.

9. Conclusions

In conclusion, we report on the design and fabrication of thermoelectric devices composed of 4-pairs of legs of PLD grown n-Bi₂Te₃ and p-Sb₂Te₃ thin films. Bi₂Te₃ and Sb₂Te₃ are simple compounds, easy to synthesize and deposit, have very high conductivity, and are naturally doped. These advantages make the cost of building devices much lower than the more complex alloys.

Our study shows that these multi-leg devices have the performance that makes them attractive for cooling/heating devices. However, these devices can even provide much higher performance, if the geometry and fabrication process are optimized to serve the application targeted. The devices fabricated achieved a maximum effective Seebeck coefficient of 146 μ V/K, a figure of merit of 0.03, and a power factor of 20.8 μ W/m·K².

Although the convention is to use Seebeck coefficient, the power factor, and the figure of merit to characterize any device, we believe that such parameters should not be used universally for all thermoelectric devices. The performance of a device used for energy harvesting, can be evaluated using the voltage sensitivity, $S_V = \Delta V/\Delta T$. However, devices used for cooling/heating application should use temperature sensitivity $S_T = \Delta T/\Delta V$, instead. Since the reported devices are designed for cooling/heating applications, temperature sensitivity represents the best indication of the device performance. For one pair of legs, our device exhibited a max S_T of 27.4 K/mV compared with 3.4 K/mV for the device reported by Kimi and Oh. However, our devices have lower voltage sensitivity of 36.5 μ V/K compared with 293 μ V/K for the device of Kimi and Oh for one pair of legs. These results support our claim that cooling and heating devices, such as ours, should be optimized to achieve higher temperature sensitivity, while energy harvesting devices should be optimized to obtain higher voltage sensitivity.

The performance of this device can be enhanced several fold, if superlattice layers are used [32]. The enhancement in these materials is mainly attributed to the controlling of the transport of phonons and photons in the super lattice. In

order to understand and confirm the results obtained by this study, a theoretical study, such as multi-physics numerical analysis, may need to be conducted [31].

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